

PROCEEDINGS OF SPIE

Optoelectronic Devices and Integration VIII

Xuping Zhang
Baojun Li
Changyuan Yu
Xinliang Zhang
Daoxin Dai
Editors

22–23 October 2019
Hangzhou, China

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Published by
SPIE

Volume 11184

Proceedings of SPIE 0277-786X, V. 11184

SPIE is an international society advancing an interdisciplinary approach to the science and application of light.

Optoelectronic Devices and Integration VIII, edited by Xuping Zhang, Baojun Li,
Changyuan Yu, Xinliang Zhang, Daoxin Dai, Proc. of SPIE Vol. 11184, 1118401
© 2019 SPIE · CCC code: 0277-786X/19/\$21 · doi: 10.1117/12.2560497

Proc. of SPIE Vol. 11184 1118401-1

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Please use the following format to cite material from these proceedings:

Author(s), "Title of Paper," in *Optoelectronic Devices and Integration VIII*, edited by Xuping Zhang, Baojun Li, Changyuan Yu, Xinliang Zhang, Daoxin Dai, Proceedings of SPIE Vol. 11184 (SPIE, Bellingham, WA, 2019) Seven-digit Article CID Number.

ISSN: 0277-786X
ISSN: 1996-756X (electronic)

ISBN: 9781510630857
ISBN: 9781510630864 (electronic)

Published by

SPIE

P.O. Box 10, Bellingham, Washington 98227-0010 USA
Telephone +1 360 676 3290 (Pacific Time) · Fax +1 360 647 1445

SPIE.org

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